Supporting Materials

Characterization of Inherently Chiral Electrosynthesized Oligomeric Films by Voltammetry and Scanning Electrochemical Microscopy (SECM)

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Figure S1
SEM Images of the bare (A) and oligomer-modified (B) polycrystalline gold electrode

A)

B)

EDX analysis of the surface

Elemental analysis: a) gold (green), b) carbon (blue), c) sulfur (red), d) mixed elements.
Figure S2- Cyclic voltammograms recorded at the bare gold electrode (2 mm diameter) in a CH$_3$CN + 0.1 M TBAPF$_6$ solution containing 1 mM each of Fc (red line), (S)-FcEA (black line), (R)-FcEA (green line) and rac(±)-FcEA (blue line) probes. Scan rate 0.050 V s$^{-1}$.
Figure S3- Cyclic voltammograms recorded at 0.005V s\textsuperscript{-1} with a Pt microdisk electrode (25 µm diameter) in the following media: CH\textsubscript{3}CN + 0.1 M TBAPF\textsubscript{6} solution containing 1 mM Fc (a), 0.6 mM \((R)\)-FcEA (b), 1 mM \((S)\)-FcEA (c), 1 mM \(rac(\pm)\)-FcEA (d) redox mediators; H\textsubscript{2}O + 0.1 M KCl solutions containing 1 mM K\textsubscript{3}[FeCN\textsubscript{6}] (e), 1 mM K\textsubscript{4}[FeCN\textsubscript{6}] (f) redox mediators. Acronyms Fc and FcEA stand for ferrocene and of \(N, N\)-dimethyl-1-ferrocenylethylamine, respectively. \(rac\)- stands for racemate of the \(S\)- and \(R\)- enantiomers.

Table S1. Half-wave potentials of the redox mediators employed in the SECM measurements

| Redox couple                        | \(E_{1/2}\) vs. Ag|AgCl / V |
|-------------------------------------|-------------------|
| Fc\textsuperscript{+}/Fc            | +0.400            |
| \((R)\)-FcEA\textsuperscript{+}/ \((R)\)-FcEA| +0.395            |
| \((S)\)-FcEA\textsuperscript{+}/ \((S)\)-FcEA| +0.390            |
| \(rac(\pm)\)-FcEA\textsuperscript{+}/ \(rac(\pm)\)-FcEA| +0.395            |
| \([FeCN\textsubscript{6}]\textsuperscript{3/-4}\) | +0.230            |
**Figure S4 - Scheme of redox mediator regeneration at the substrate**

The substrate under investigation is immersed in a solution containing the electroactive specie $R$, which can undergo the following reversible redox reaction:

$$R \rightleftharpoons O + e^-$$

At the SECM tip, a high positive potential is applied (i.e., more positive to the the halfwave potential, $E_{1/2}$, of the $O/R$ couple), such that $R$ is oxidised to $O$ at a diffusion control rate (see Scheme S4a).

The redox mediator regeneration can also occurs at the unbiased substrate (Scheme S4b). This is because a significant area of the substrate below the tip, and away from it, is bathed by the solution whose concentration has not been perturbed by the tip-reaction [1-6]. Thus, in the latter zone, the substrate is poised at a potential established by the species $R$ in the bulk solution and, at open circuit, its value is negative to the halfwave potential ($E_{1/2}$) of the $O/R$ couple. When the tip approaches the substrate, the portion of the substrate directly under the tip is exposed to the electrode reaction product, $O$, and at a more positive potential. In this case, the localized reduction current at the portion of the substrate under the tip is driven by the oxidation of $R$ at those portions of substrate away from the tip region [6]. This provides a lateral electron transport through the conducting material.

It must be noted that the potential of an unbiased substrate is also perturbed by current flow, which is required for recycling the mediator [4]. Thus, the feedback response can also be perturbed by finite heterogeneous electron-transfer kinetics [4].

In general, the lateral electron transport of Scheme S4b is operative in a conductive substrate whose surface area is larger than that of the micro-tip counterpart. In this work, the latter condition is fulfilled in the SECM experiments performed only at the bare gold electrode. Apparently, it was not the case for the measurements performed at the oligo-(S)-BT$_2$T$_4$-Au, as discussed in the main manuscript.
S5. Estimate of the average roughness of the bare gold and oligo-(S)-BT$_2$T$_4$-Au surfaces by SECM

The surface roughness profiles of the bare gold and oligo-(S)-BT$_2$T$_4$-Au surfaces were evaluated by using the current oscillations obtained in the 1-D scans. The current values were preliminarily normalized for the bulk current obtained for the specific redox mediator employed. The arithmetic mean current value ($R_I$) measured along a line was evaluated:

$$ R_I = \frac{1}{N} \sum_{i=1}^{N} |I_i| $$

The amplitude of the current oscillation between the maximum peak ($\max \; i I_i$) and minimum valley ($\min \; i I_i$) were also evaluated. The maximum peak to valley height ($R_{tmax}$) was then established:

$$ R_{tmax} = \max \; i I_i - \min \; i I_i $$

The values thus established were interpolated to the theoretical approach curves to transform current in normalized distance, $d/a$. By the knowledge of the microelectrode radius, roughness average ($R_a$) and maximum peak to valley height ($R_{max}$) were evaluated.

References